

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named		
Inventor :	Benjamin Y.H. Liu	
Appln. No.:	10/769,011	Group Art Unit: 1792
Filed :	January 30, 2004	
For :	HIGH-PERFORMANCE AND MULTI- LIQUID-PRECURSOR VAPORIZATION IN SEMICONDUCTOR THIN FILM DEPOSITION	Examiner: Bueker, Richard R.
Docket No.:	M419.12-0043	

**AMENDMENT ACCOMPANYING REQUEST
FOR CONTINUED EXAMINATION**

**FILED ELECTRONICALLY
DECEMBER 4, 2008**

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This Amendment responds in part to the Official Action relating to claims 2-6, 12 and 22-27 dated August 5, 2008. It also responds in part in relation to newly submitted claims to the Official Action dated September 7, 2008.

Please amend the above-identified application as follows.